Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	3	(ground$3 and (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (outer or edge$1 or border$1 or periphery))	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 15:27
L2	1	(ground$3 and (e-beam or (electron adj beam))).ti. and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (outer or edge$1 or border$1 or periphery))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 15:25
L3	31	((e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (outer or edge$1 or border$1 or periphery))	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:40
L4	116	((e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (outer or edge$1 or border$1 or periphery)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:14
L5	90	(photomask and chromium and photoresist).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:21
L6	22	l5 and (outer or edge$1 or border$1 or periphery).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:22
L12	1151	((photomask or mask$3) and (chromium or Cr) and ($5resist or photosensitive or photopolymer or photocurable or photo-curable or uv-curable)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:22
L13	209	l12 and (outer or edge$1 or border$1 or periphery).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:26

L15	406	l12 and (outer or edge$1 or border$1 or periphery or side$1 or tab$1).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:27
L16	377	l15 and (etch$3 or remov$3).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:28
L18	30	l15 and ((e-beam or (electron adj beam)) and (etch$3 or remov$3)). clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:28
L19	355	rolfson.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:38
L20	23	rolfson.in. and chromium and photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:39
L21	23	(rolfson and brett).in. and chromium and photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:39
L22	176	(rolfson and brett).in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:39
L26	55	((nozzle or source) and etch$3 and (chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (outer or edge$1 or border$1 or periphery)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:43
L27	8	((nozzle or source) and etch$3 and (chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (outer or edge$1 or border$1 or periphery))	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:42

L28	245	(156/345.1).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:44
L29	44	(156/345.17).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:44
L30	38	(156/345.19).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:44
L31	112	(l28 or l29 or l30) and (etchant or solvent or solution) and (nozzle or source)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:46
L32	51	(l28 or l29 or l30) and (etchant or solvent or solution) and (nozzle or source) and (edge$1 or side$1 or border or periphery or outer).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:46
L33	14	(l28 or l29 or l30) and ((etchant or solvent or solution) and (nozzle or source) and (edge$1 or side$1 or border or periphery or outer)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 17:22
L34	4	(("5804336") or ("6261427")).PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 17:23
S1	1817	216/2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:44
S2	265	216/12	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:44
S3	1062	216/41	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:47

S4	2374	438/689	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:46
S5	2306	156/242	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:46
S6	2514	156/247	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:46
S7	354	355/78	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:46
S8	2	355/152	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:46
S9	4739	(216/41-54).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:47
S10	1222	(216/41).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:47
S11	765	(430/4).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:48
S12	7486	(430/5).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:48
S13	428	(430/256).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:48

S14	672	(430/269).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:48
S15	241	(430/291).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:48
S16	463	(430/292).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:48
S17	23283	(430/296-331).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:48
S18	2129	(438/942-952).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:49
S19	876	(S17 or S18) and (chrome or chromium).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:50
S20	578	(S17 or S18) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 16:12
S21	3	(ground with (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:56
S22	5	(ground with (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive)) .	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:53
S23	1	2004-744613.NRAN.	DERWENT	OR	OFF	2005/07/12 14:56
S24	54	(ground with (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 18:09

S25	11	(ground with (e-beam or (electron adj beam))) same ((chrome or chromium) same (resist or photoresist or photopolymer or photosensitive))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:59
S26	11	(ground with (e-beam or (electron adj beam))) same ((chrome or chromium) same (resist or photoresist or photopolymer or photosensitive or photomask))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/12 14:59
S27	17	(ground$3 with (e-beam or (electron adj beam))) same ((chrome or chromium) same (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 18:12
S28	9	(ground$3 and (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable))	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 18:12
S29	1543	(ground$3 and (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable))	US-PGPUB; USPAT	OR	OFF	2005/07/20 18:32
S30	74	(ground$3 with (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable))	US-PGPUB; USPAT	OR	OFF	2005/07/20 18:30
S31	2	((ground$3 and (e-beam or (electron adj beam))) and (chrome or chromium) and (borosilicate or silica$3)).clm.	US-PGPUB; USPAT	OR	OFF	2005/07/20 18:31
S32	2	((ground$3 and (e-beam or (electron adj beam))) and (chrome or chromium) and (tab or tabs)).clm.	US-PGPUB; USPAT	OR	OFF	2005/07/20 18:31
S33	550	(ground$3 and (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (silica$3 or borosilicate$1))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 18:34

S34	1	((e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (silica$3 or borosilicate$1) and ground$3)	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 18:33
S35	11	(ground$3 and (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (silica$3 or borosilicate$1)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/21 10:51
S36	9	(ground$3 and (e-beam or (electron adj beam))) and ((chrome or chromium) and (resist or photoresist or photopolymer or photosensitive or uv-sensitive or photo-curable or uv-curable) and (edge$1 or border$1 or periphery)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/23 15:24